



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

YEUNG et al.

Serial No.: 09/698,149

Art Unit: 1711

Filed: October 30, 2000

Examiner: O. Asinovsky

For: BLOCK POLYMERS, COMPOSITIONS AND METHODS OF USE FOR FOAMS, LAUNDRY DETERGENTS, SHOWER RINSES AND COAGULANTS

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to Rules 56 and 98, Applicants hereby call the attention of the Patent Office to the references listed on the attached Form PTO 1449.

Applicants present these references so that the Patent Office may, in the first instance, determine any relevancy thereof to the presently claimed invention, see Beckman Instruments, Inc. v. Chemtronics, Inc., 439 F.2d 1369, 1380, 165 USPQ 355, 364 (5th Cir. 1970). Also see Patent Office Rule 104. Applicants respectfully request that these references be expressly considered during the prosecution of this application and made of record herein and appear among the "References Cited" on any patent to issue herefrom.

Respectfully submitted,

By:

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Date: Oct 10, 2003

APV/kag
ATTORNEY DOCKET NO. APV30271CIP

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FORM PTO-1449 U.S. Department of Commerce (Rev. 4/92) Patent and Trademark Office		ATTY. DOCKET NO. APV30271CIP	SERIAL NO. 09/698,149
INFORMATION DISCLOSURE STATEMENT BY APPLICANT <small>(Use several sheets if necessary)</small>		APPLICANT YEUNG et al.	
		FILING DATE October 30, 2000	GROUP

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

US Patent Application No. 09/698,479 filed October 30, 2000 in the name of Vance BERGERON et al.

EXAMINER _____ DATE CONSIDERED _____

EXAMINER: Initial if citation is considered, draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.